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Patent

Attorney's Docket No. 015290-508

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Patent Application of)	
)	
Paul K. SHUFFLEBOTHAM et al.)	Group Art Unit: 1763
)	
Application No.: 09/775,664)	Examiner: R. Zervigon
)	
Filed: February 5, 2001)	Confirmation No.: 9320
)	
For: INDUCTIVELY COUPLED)	
PLASMA CVD)	

AMENDMENT

Assistant Commissioner for Patents
Washington, D.C. 20231

Sir:

In response to the Official Action mailed July 31, 2002, a Petition for an Extension of Time (one month) and the requisite fee being submitted herewith, please amend the above-identified application as follows.

IN THE SPECIFICATION:

Page 12, before line 30, insert the following new paragraph:

A plurality of gas flows can overlap each other in a plane parallel to an exposed surface of the substrate.

IN THE CLAIMS:

Please replace Claims 50, 56-63 and 65-67 and add new Claim 71 as follows: